Intermediate band solar cell materials through the doping of group-VA elements (N, P, As and Sb) in Cu$_2$ZnSiSe$_4$

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The electronic structure and optical properties of group-VA (N, P, As, and Sb)-doped Cu$_2$ZnSiSe$_4$ alloys have been studied using a hybrid functional through density functional theory calculations. The minor lattice distortion and small formation energy indicate that synthesis of these alloys is highly possible in experiment. For each doped alloy, an isolated and partially filled intermediate band (IB) appears in its band structure. The doping-induced IB is mainly contributed by the s states of the doped group-VA atom and the p states of four neighboring Se atoms, and slightly by the d states of eight Cu atoms. The existence of an IB obviously enhances the absorption coefficient with two additional absorption peaks in the visible light range. For P, As and Sb-doped Cu$_2$ZnSiSe$_4$ alloys, not only the bandgap between the valence band maximum and the conduction band minimum but also the sub bandgap between the valence band maximum and the IB are very close to the optimal values for visible light absorption. Therefore, these alloys are recommended as good candidates for IB solar cell materials.

1. Introduction

Intermediate band (IB) materials have attracted great attention due to their promising ability to enhance the efficiency of solar cells. The IB locates between the valence band maximum (VBM) and the conduction band minimum (CBM). To achieve high photocurrent and photo-voltage, the IB should be isolated and partially filled. Therefore, electrons can be excited not only from the VB to the CB, but also from the VB to the IB and from the IB to the CB. The detailed balance efficiency limit of IB solar cells (IBSCs) (63.1%) is greatly higher than that of ordinary single-junction solar cells (30%).

Many investigations have been carried to fabricate various kinds of IBSCs. First typical IBSC is designed and manufactured using quantum dot (QD) technology. Photocurrent produced by the electron transition from IB to CB is experimentally measured. However, the IBSCs fabricated by QD technology have low density of states (DOS) in the IB and small bandgap in the host material (such as 1.42 eV for GaAs). Both of the factors substantially limit the enhancement of their efficiency. It is reported that the optimal bandgap for IBSCs at 1 sun is 2.41 eV with IB locating at 0.92 eV from the CB or the VB. Chalcopyrite CuGaS$_2$ is regarded as an excellent host for IBSCs due to its appropriate bandgap (2.43 eV). The IBs are predicted to be formed by doping of 3d-metal atoms such as Ti, Cr, Fe, and Ni in CuGaS$_2$. The shortcomings of the IBs induced by doping of Ti, Fe and Ni in CuGaS$_2$ are occupied or unoccupied based on relatively accurate hybrid functionals, but not partially filled states which are expected in practical applications. Furthermore, Yang et al. proposed that transition metals might not be the best dopant to fabricate IBSCs. The localized 3d states of transition metals may result in low light absorption coefficient and low carrier mobility. Elements from group-IV and VA as dopants create delocalized s states which could be more appropriate to enhance the parameters. For the host of Cu$_2$ZnSnS$_4$, the doping of Sb at Sn site has the lowest formation energy than other sites such as Cu, Zn and S. By using more accurate hybrid functional instead of the generalized gradient approximation (GGA), it is predicted that partially filled IBs can form in Sn-doped CuInS$_2$ and CuGaS$_2$, (P, Sb)-codoped CuGaS$_2$ at Ga and S sites, (Si, Ge, Sn)-doped AgAlTe$_2$, and Sb-doped Cu$_2$ZnSnS$_4$. Whereas, the use of toxic or costly elements, like Ga, Ag, Te or In, in the host materials is highly demanded to be replaced by nontoxic and cheap elements.

In this paper, the Cu$_2$ZnSiSe$_4$ alloy is chosen as host material, whose bandgap (2.33 eV) is very close to the ideal value (2.41 eV) for IBSCs. The group-VA elements (N, P, As, and Sb) are selected as dopants to replace Si atom in order to easily form n-type semiconductor. The delocalized s states of group-VA elements will help to form delocalized IBs and generate freely transported carriers. Our calculation shows that an isolated and partially filled IB is induced in all the four doped alloys. The IB...
is dominated by the hybridization of M-s and Se-p states as well as slightly contributed by Cu-d states. Compared with that of the host material, absorption coefficient of group-VA doped Cu$_2$ZnSiSe$_4$ is largely enhanced with additional two peaks in the visible light range.

2. Computational details

All calculations are performed with in the density functional theory (DFT) using Vienna *Ab initio* Simulation Package (VASP)\(^{21,22}\) with the projector augmented wave (PAW) method.\(^{23}\) The plane-wave energy cutoff is set to 400 eV. Our previous study has revealed that the total energy of Cu$_2$ZnSiSe$_4$ in kesterite (KS) structure (Fig. 1a) is lower than those in stannite and wurtzite-stannite structures through both GGA and hybrid functional calculations.\(^{34}\) Experimentally, Cu$_2$ZnSiSe$_4$ and Cu$_2$ZnSiS$_4$ are observed in wurtzite-stannite structure\(^{25,26}\) but Cu$_2$ZnGeSe$_4$ in KS structure.\(^{37}\) Here, a 2 × 2 × 1 supercell of KS structure is used which includes 64 atoms. One Si atom is replaced by one group-VA atom M, the bond change occurs at the local geometry around dopant. The bond length of Si-Se (M = N, P, As and Sb) substitutions of one Si atom by one group-VA atom M, the bond change occurs at the local geometry around dopant. The bond length of Si-Se (M = N, P, As and Sb) is adjusted to 0.35, which de

The band structure and optical property are calculated through hybrid functional, which is known to be more accurate than GGA in prediction of electronic property of semiconductors. However, the calculated bandgap of Cu$_2$ZnSiSe$_4$ is 1.76 eV through standard HSE06,\(^{23}\) which is obviously still smaller than the experimental value (2.33 eV).\(^{28}\) The bandgap depends on the mixing parameter $\alpha$, which defines the fraction of exact exchange and is set as 0.25 in HSE06.\(^{28}\) When the value of $\alpha$ is adjusted to 0.35, the corresponding bandgap is increased to 2.26 eV, which is much closer to the experimental value. The adjustment of $\alpha$ is also adopted in the calculation of Cu$_2$ZnSnS$_4$ (ref. 17) and Cu$_2$CdZn$_{1-x}$Sn$_x$S$_4$.\(^{31}\) In this study, all calculations have used an increased $\alpha$ value (0.35).

3. Results and discussion

Our calculations show that the lattice constants ($a$ and $c$) decrease in the presence of the N substitution and increase in the presence of the P, As and Sb substitutions (Fig. 1a and b). For the P-doped alloy, the lattice variation is only 0.16% due to atomic radii of the doped P element close to the one of Si element. Even for the elements with larger atomic number (As, Sb), the lattice variations are less than 0.6%, indicating that the lattice distortion is minor. Such minor lattice distortion is quite favorable to the synthesis of doped alloys. Actually, primary change occurs at the local geometry around dopant. The bond length of Si-Se in the host Cu$_2$ZnSiSe$_4$ is 2.337 Å. After the substitution of one Si atom by one group-VA atom M, the bond lengths of M-Se (M = N, P, As and Sb) are 2.199, 2.438, 2.543 and 2.683 Å, respectively. In accordance with atomic radii, the variation is smallest by the doping of P and largest by that of Sb. To evaluate the miscibility of group-VA doped Cu$_2$ZnSiSe$_4$ alloys, the formation enthalpy $\Delta H(M)$ is defined and calculated as:

$$\Delta H(M) = E_{Cu_2ZnSiSe_4} - E_{Cu_2ZnSi_0.875M_0.125Se_4} = 0.875E_{Cu_2ZnSiSe_4} - 0.125E_{Cu_2ZnMSe_4}$$

where $E_{Cu_2ZnSiSe_4}$, $E_{Cu_2ZnSi_0.875M_0.125Se_4}$ and $E_{Cu_2ZnMSe_4}$ are the total energies of Cu$_2$ZnSi$_{0.875}$M$_{0.125}$Se$_4$, Cu$_2$ZnSiSe$_4$ and Cu$_2$ZnMSe$_4$ alloys, respectively. In consistence with the lattice distortion, formation enthalpy is smallest for the doping of P (2.69 meV per atom) and largest for the doping of Sb (6.01 meV per atom) (Fig. 1c). These formation enthalpies are smaller than that of currently commercialized solar cell material Cu(In$_{0.5}$Ga$_{0.5}$)Se$_2$(11 meV per atom),\(^{22}\) and comparable to that of IBSC Ag(Al,Sn)Te$_2$(3.75 meV per atom),\(^{33}\) and those of same host Cu$_2$Zn(Si$_{0.25}$Sn$_{0.75}$)Se$_4$ (2.8 meV per atom),\(^{33}\) and

![Figure 1](image-url)

**Fig. 1.** (a) Crystal structure of Cu$_2$ZnSiSe$_4$ in kesterite (KS) phase. The Cu, Zn, Si, and Se atoms are represented by blue, grey, orange and green spheres, respectively. (b) The calculated lattice constants. (c) Formation enthalpy of group-VA doped Cu$_2$ZnSi$_{0.875}$M$_{0.125}$Se$_4$ (M = N, P, As and Sb) alloys.
Cu$_2$ZnSn(S$_{0.75}$Se$_{0.25}$)$_4$ (5.0 meV per atom), indicating that synthesis of group-VA doped Cu$_2$ZnSiSe$_4$ alloys are highly possible in experiment.

Band structures of the host and doped alloys are shown in Fig. 2a. The calculated bandgap of Cu$_2$ZnSiSe$_4$ (2.26 eV) agrees well with the experimental value (2.33 eV). Energy interval of 0.40 eV between the VBM and the Fermi level ($E_F$) is smaller than that value of 1.86 eV between the $E_F$ and the CBM. After the doping of group-VA atom M (M = N, P, As and Sb), the bandgaps between CBM and VBM ($\Delta_{\text{CBM-VBM}}$) are among 2.21–2.39 eV, close to that of host (Fig. 2b). The most significant variation in band structure is the introduction of IB. For all the four doped cases, IBs are isolated and partially filled. This is exactly what IBSCs need to ensure the three-photon absorption processes. As indicated in Fig. 2a, IBs introduced by these four dopants have similar shapes, but positions of the band edges (CBM and VBM) show dependence on the specific dopants. Fig. 2b shows the bandgap and two sub bandgaps of doped alloys, one is between the CBM and IB at the $\Gamma$ point ($\Delta_1_{\text{CBM-IB}}$) and the other is between the IB and VBM at the $\Gamma$ point ($\Delta_2_{\text{IB-VBM}}$). It is noticed that shapes of the edges of VBM and CBM have no big difference among four doped alloys. The N-doped alloy has the largest $\Delta_1_{\text{CBM-VBM}}$. 

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Fig. 2  (a) The band structures of host material (Cu$_2$ZnSiSe$_4$) and group-VA doped alloys Cu$_2$ZnSi$_{0.875}$M$_{0.125}$Se$_4$ (M = N, P, As and Sb). Fermi level of each alloy is set to zero (b) the bandgap between CBM and VBM, and two sub bandgaps between CBM and IB, IB and VBM, respectively. The dotted line represents the optimal value of sub bandgap for IBSCs.
CBM–IB (2.09 eV) and the smallest Δ_{2 IB-VBM} (0.29 eV). In contrast, the P-doped alloy has the smallest Δ_{1 CBM-IB} (1.30 eV) and the largest Δ_{2 IB-VBM} (1.00 eV), which will be discussed later.

Fig. 3a and b show the total DOS and projected DOS (PDOS) of group-VA doped Cu_{2}ZnSiSe_{4} alloys. The VBM are mainly composed by Cu-3d and Se-4p states (Fig. 3b), same as the host material. As to the conduction band, a prominent peak locates at about 2.0 eV. Beside the Se-4p and Si-3s states, there is obvious contribution from the p states of doped elements M (M = N, P, As and Sb) to this peak. Fig. 3c plots the isosurface of the band-decomposed charge density of IB for the P-doped alloy. IB charge density is contributed dominantly by one doping atom (P) and four neighboring Se atoms, as well as slightly by eight adjacent Cu atoms in the supercell. Similarly, the IBs of other three doped alloys are also primarily composed by the antibonding states of M-s and Se-4p. The atomic orbital energies of N-2s, P-3s, As-4s and Sb-5s are −18.58, −13.97, −14.49 and −12.83 eV, respectively. Since the atomic orbital energy of N-2s is much lower than the other three, the corresponding IB formed by the anti-bonding hybridization of N-2s and Se-4p is at the lowest position and closest to the VBM, resulting in the smallest Δ_{2 IB-VBM}. Besides the atomic orbital energy, interactions between doped elements and Se atoms are influenced by their bond lengths. Although atomic orbital energy of P-3s (−13.97 eV) is lower than that of Sb-5s (−12.83 eV), the bond length of P-Se (2.438 Å) is smaller than that of As-Se (2.683 Å). The anti-bonding state by P-3s and Se-4p is pushed to a higher energy than that by Sb-4s and Se-4p. Therefore, the IB of P-doped alloy stays at the highest position among four antibonding states and has the largest value of Δ_{2 IB-VBM}, as indicated in Fig. 2b.

Fig. 4 compares optical absorption coefficients α(ω) of group-VA doped alloys with that of the host material. Solar spectrum is also shown in the background. It can be seen that the difference of α(ω) in the zz and xx directions (parallel to the c and a axis, respectively) is insignificant. For the host of Cu_{2}ZnSiSe_{4} (blue lines in Fig. 4), there is only one absorption peak (2.62 eV) at the main solar light energy range, which corresponds to the electron transition from the VB to the CB. Furthermore, absorption coefficient is considerably small when the photon energy is lower than 2.0 eV.
below 2.0 eV. It is noticed that there are three absorption peaks (labeled as I, II, and III, respectively, in Fig. 4) for each doped alloy. The peak I, caused by electron transition from VB to CB, slightly shifts to higher energy for the doping of N and P but shifts to lower energy for the doping of Sb. This is due to the bandgap between the VBM and CBM slightly increases for the doping of N and P and decreases for the doping of Sb. The additional two peaks (II and III), caused by electron transitions from the IB to CB and from the VB to IB, locate at lower energy with more intensity of the solar light. Therefore, the absorption energy range is substantially broadened and the absorption coefficient is greatly enhanced due to dopant-introduced IBs. It is worth noticing that except N-doped alloy, the sub bandgaps $D_{2\text{IB-VBM}}$ of P, As and Sb-doped alloys (1.00, 0.64 and 0.80 eV, respectively) are very close to the optimal value (0.92 eV), indicating that these doped alloys are promising candidates for the IBSC materials.

4. Conclusions

We have investigated electronic and optical properties of the group-VA (N, P, As, and Sb)-doped Cu$_2$ZnSiSe$_4$ alloys through hybrid functional calculations. The band structure predicted with an adjusted mixing parameter $\alpha$ (0.35) is more accurate than that through standard HSE06 functional. An isolated and partial filled IB is introduced by the doping of group-VA elements. IBs are formed dominantly by the anti-bonding hybridization of doped M-s states (M = N, P, As and Sb) and Se-4p states. For all of the four doped alloys, three absorption peaks can be clearly observed in the spectra and corresponding to the electron transitions from the VB to CB, IB to CB and VB to IB, respectively. The absorption energy range is substantially broadened and the absorption coefficient is greatly enhanced. This result indicates that group-VA doped Cu$_2$ZnSiSe$_4$ alloys are promising intermediate band solar cell materials with high absorption efficiency for solar energy.

Conflicts of interest

There are no conflicts of interest to declare.

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